

6th RD51 Collaboration Meeting
7-10 October 2010 Bari, Italy

Ultrashort pulsed laser technology for new detectors

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Outline

- Laser ablation: a short introduction
- Laser drilling techniques
- Critical aspects of GEM fabrication via laser ablation
- Laser Materials Processing lab @ CNR-IFN Bari
- Preliminary results
- Outlook

Laser Ablation Definition

Laser ablation is the process of removing material from a solid surface by irradiating it with a laser beam.

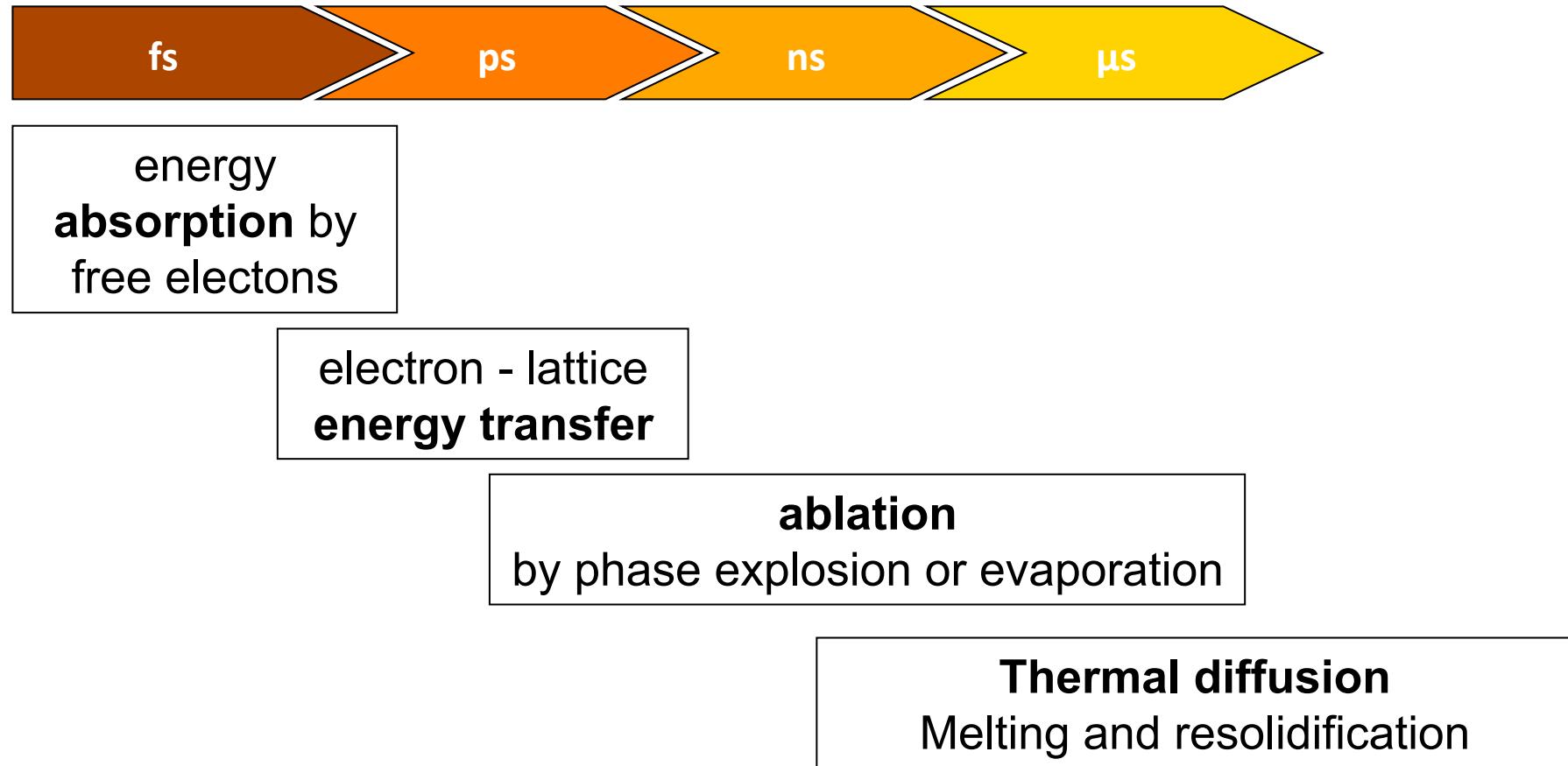
At low laser flux, the material is heated by the absorbed laser energy and evaporates or sublimates.

At high laser flux, the material is typically converted to a plasma.

Usually, laser ablation refers to removing material with a pulsed laser

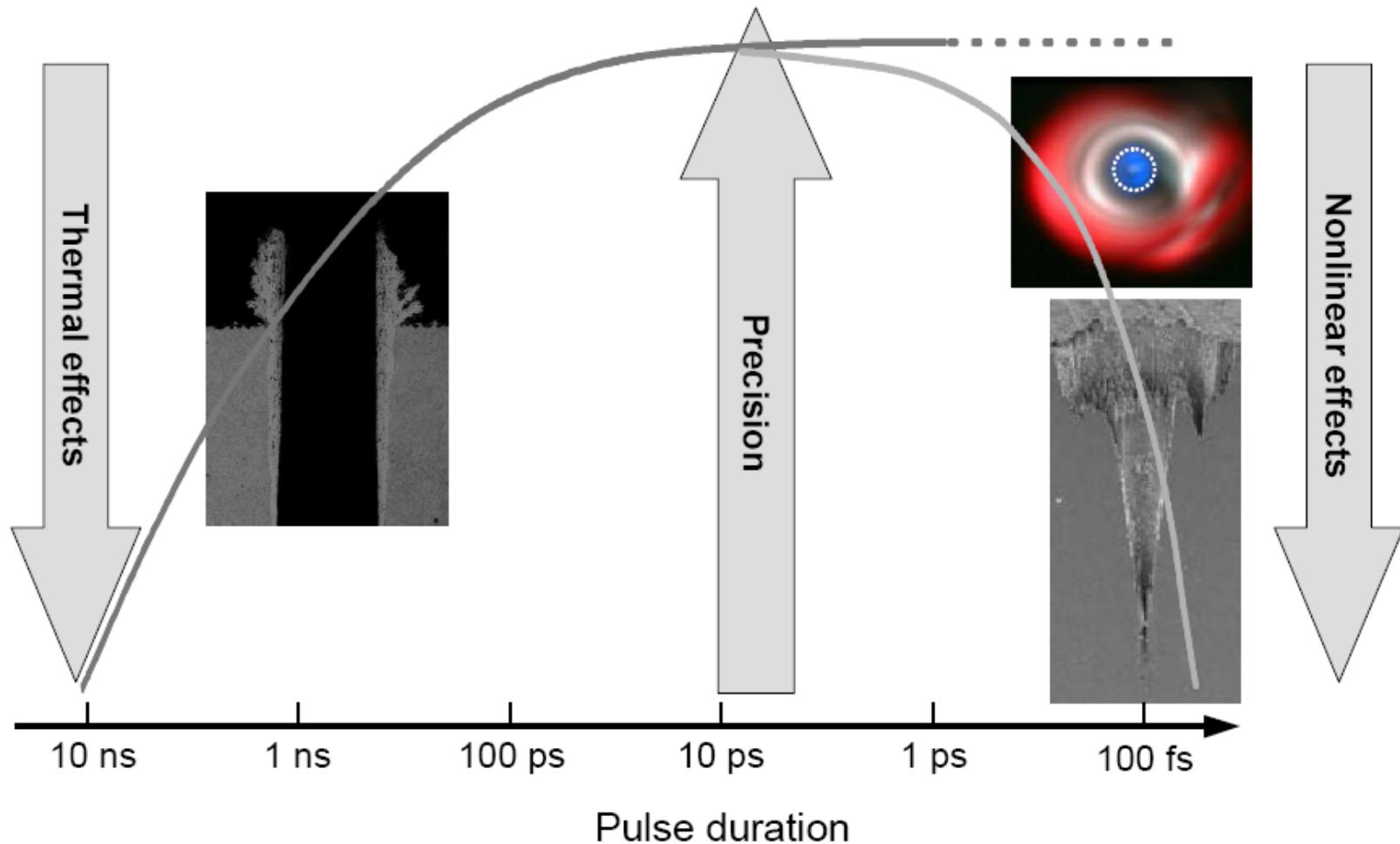


Timescales of the laser ablation process



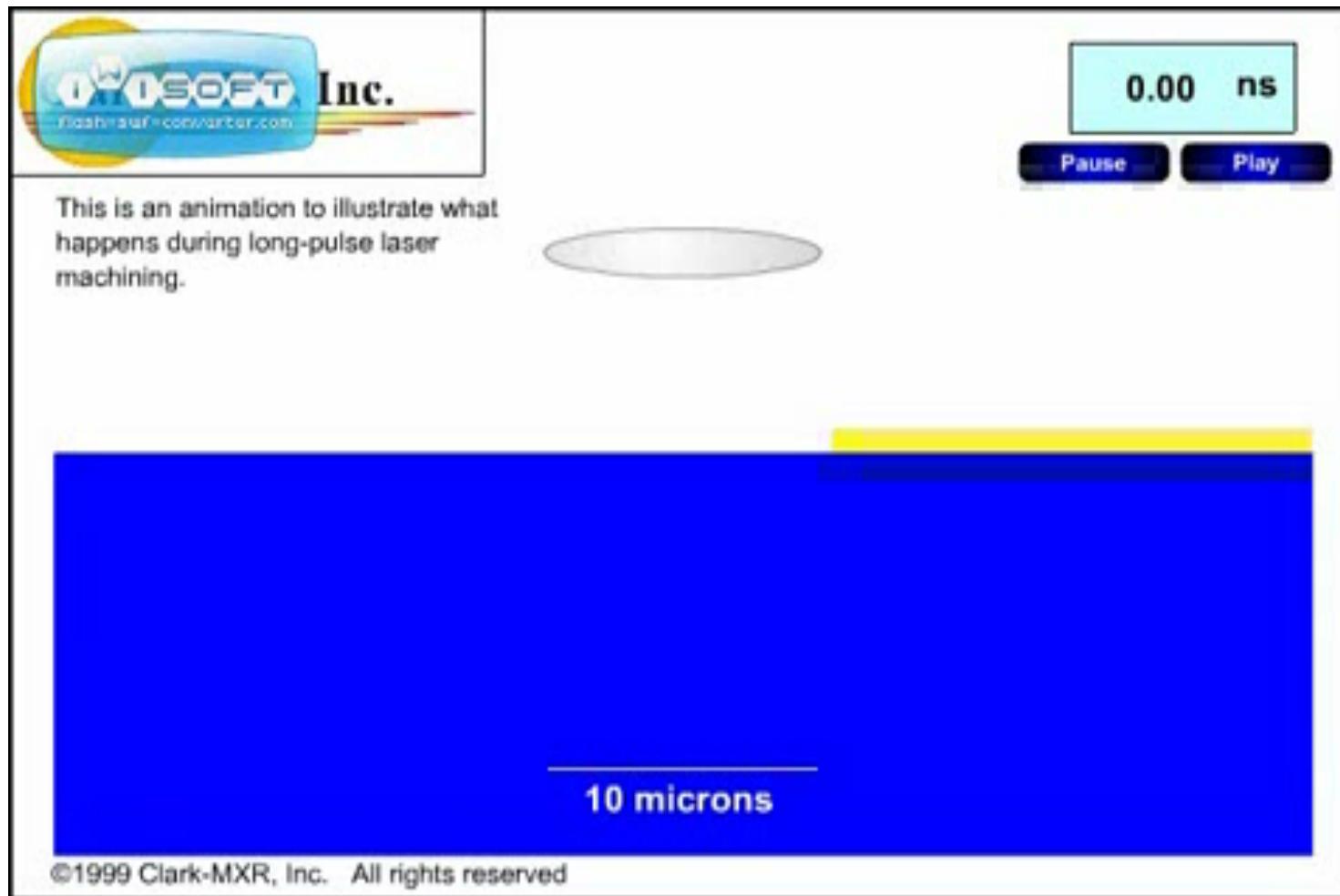
Mazur *et al.* *Nature Materials* **2**, 217 (2002)

Precision Vs. Pulse duration



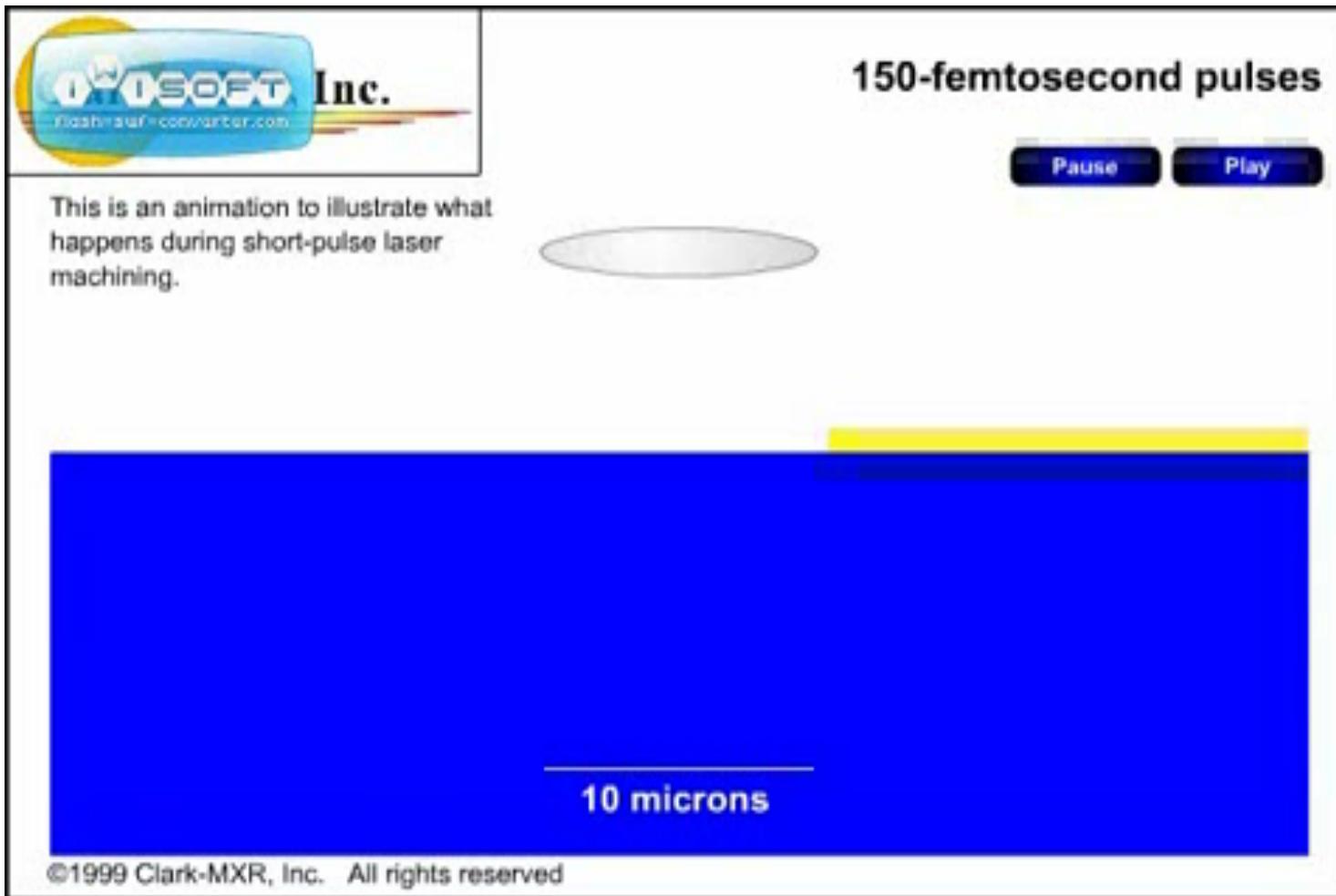
F. Dausinger, Proc. FTK, 289-308 Stuttgart 2003

Laser ablation with long pulses



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Laser ablation with short pulses



Micromachining of metals



“long” pulses (3.3 ns)

- melting and creation of burr
- heat diffusion
- non reproducible process

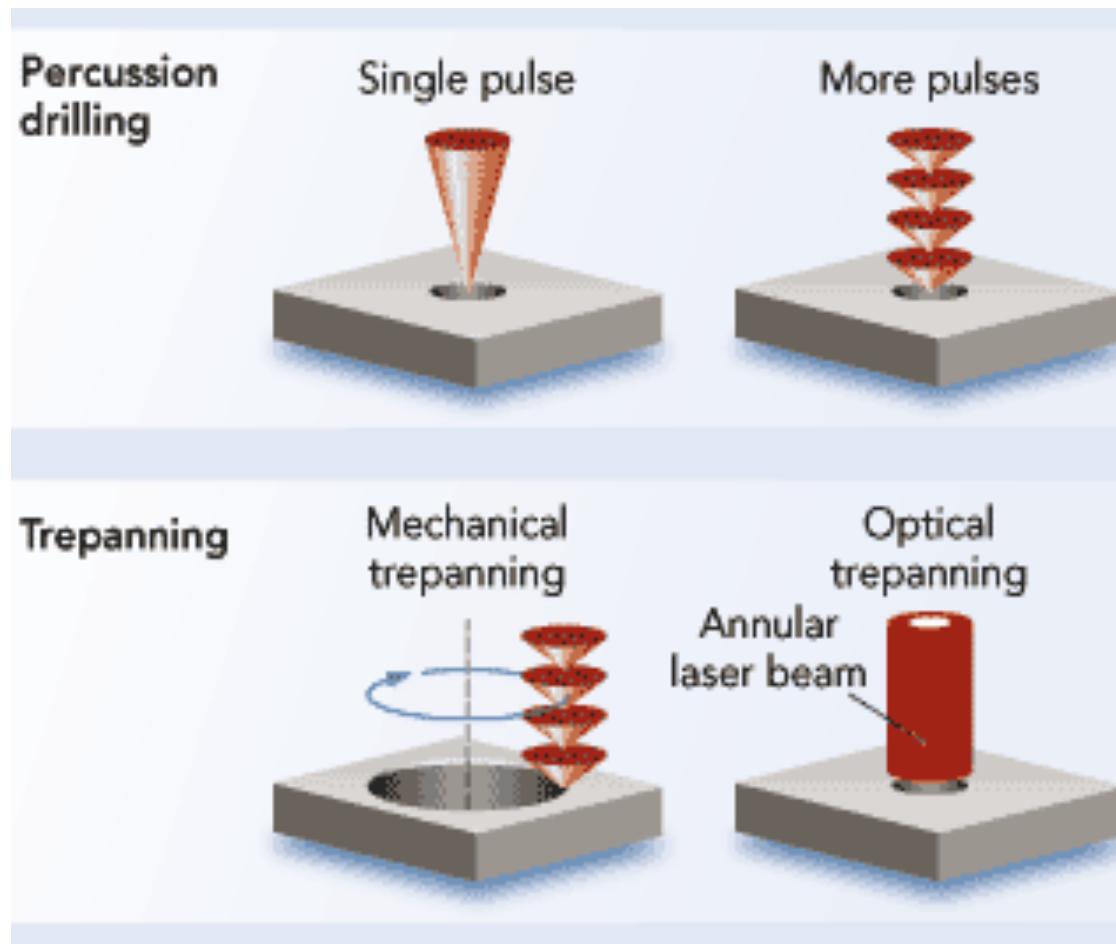
C. Momma et al. Opt. Comm. 129 (1996)



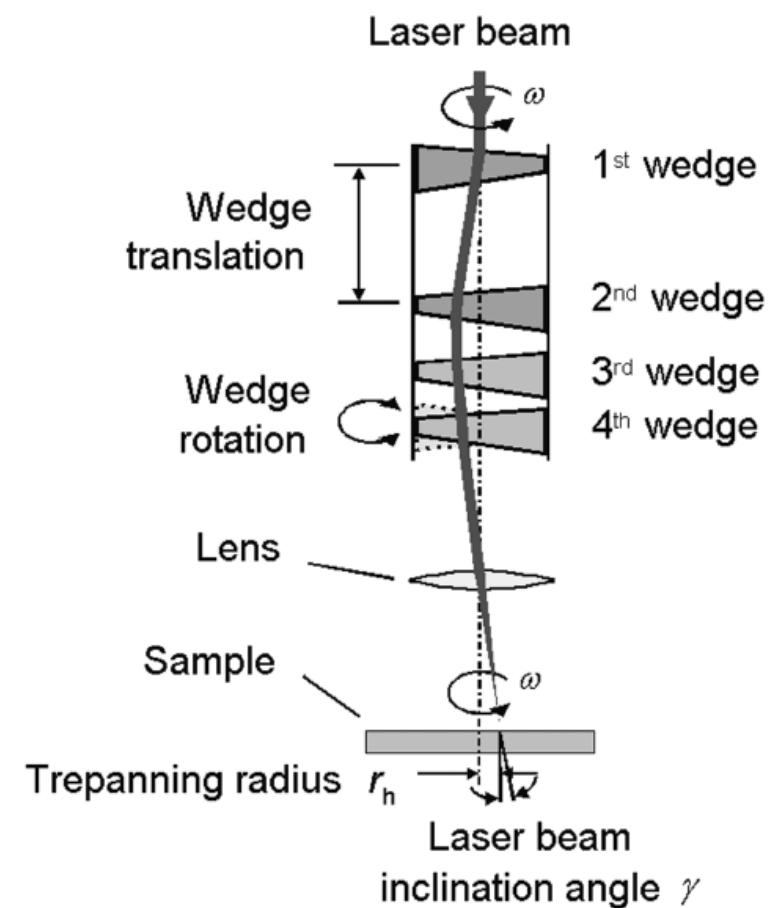
Ultrashort pulses (200 fs)

- practically burr- and melting-free ablation
- low ablation threshold
- negligible heat diffusion
 - minimized heat affected zones
- high process efficiency
- stable ablation process
 - high reproducibility

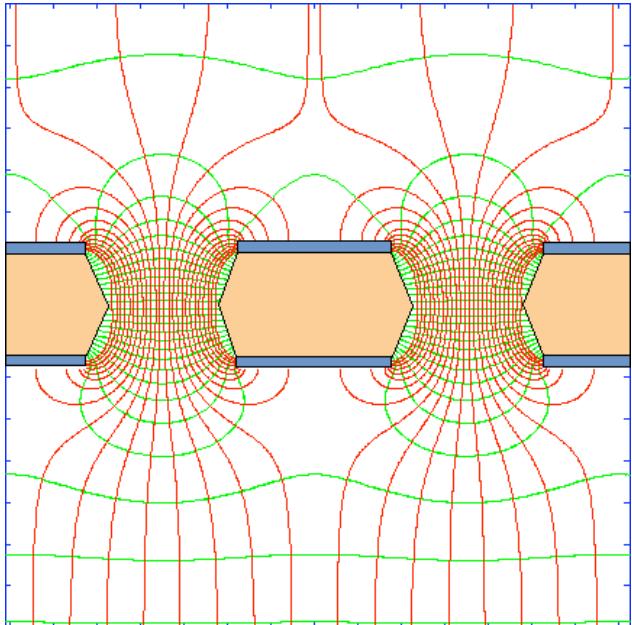
Laser drilling strategies for high accuracy



Trepanning optic for helical drilling

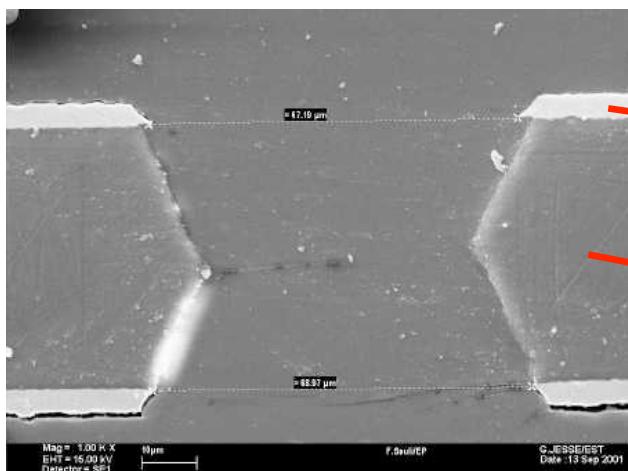
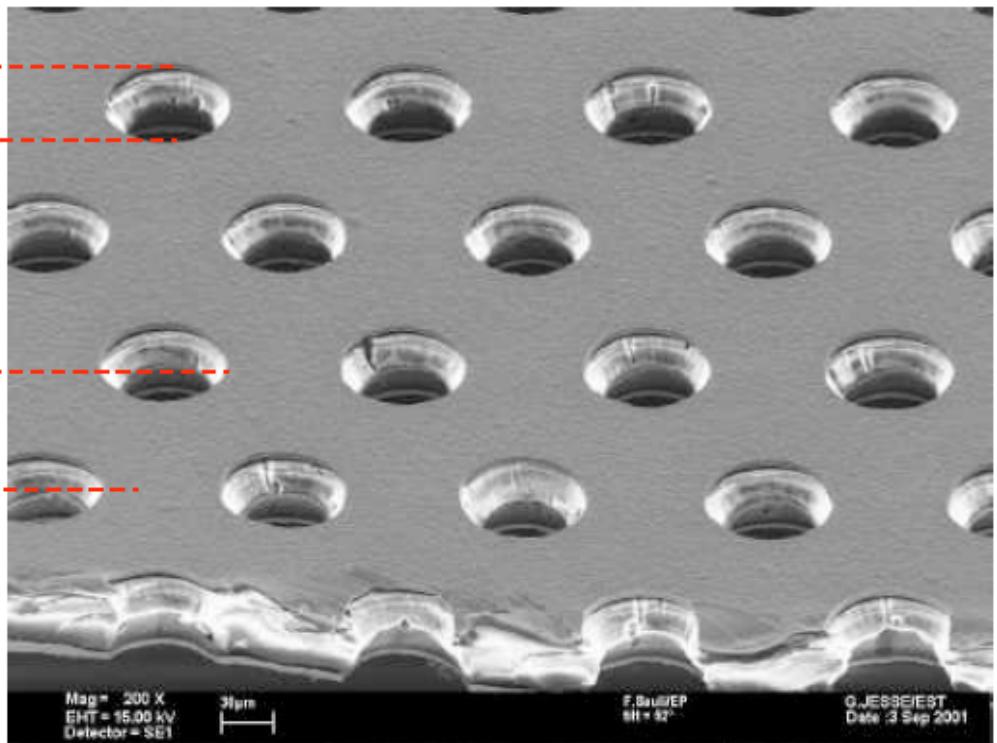


GEM fabrication



70 μm

140 μm



5 μm Copper

50 μm Kapton

Critical aspects of GEM fabrication via laser ablation

- Kapton and Cu are materials with completely different thermal and physical properties

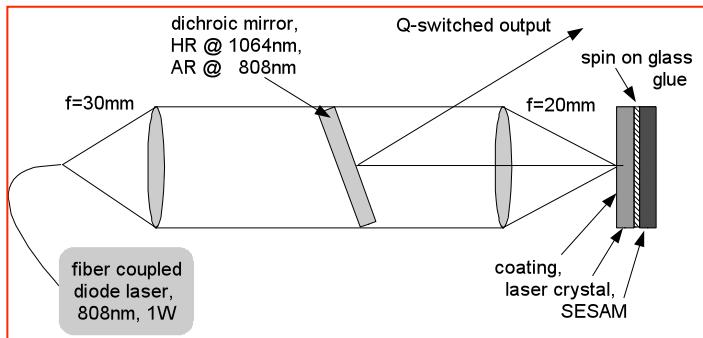
	Material	Density (g cm ⁻³)	Thermal Conductivity (W m ⁻¹ K ⁻¹)	Melting point (°C)	Vaporization temperature (°C)
Copper	Metal	8.94	400	1084	2562
Kapton	Polymer	1.42	0.12	none	~ 600

- Finding optimal laser process parameters
(pulse duration, wavelength, fluence, drilling strategy)
- Copper particle redeposition inside the hole walls
(post process etching could be required)

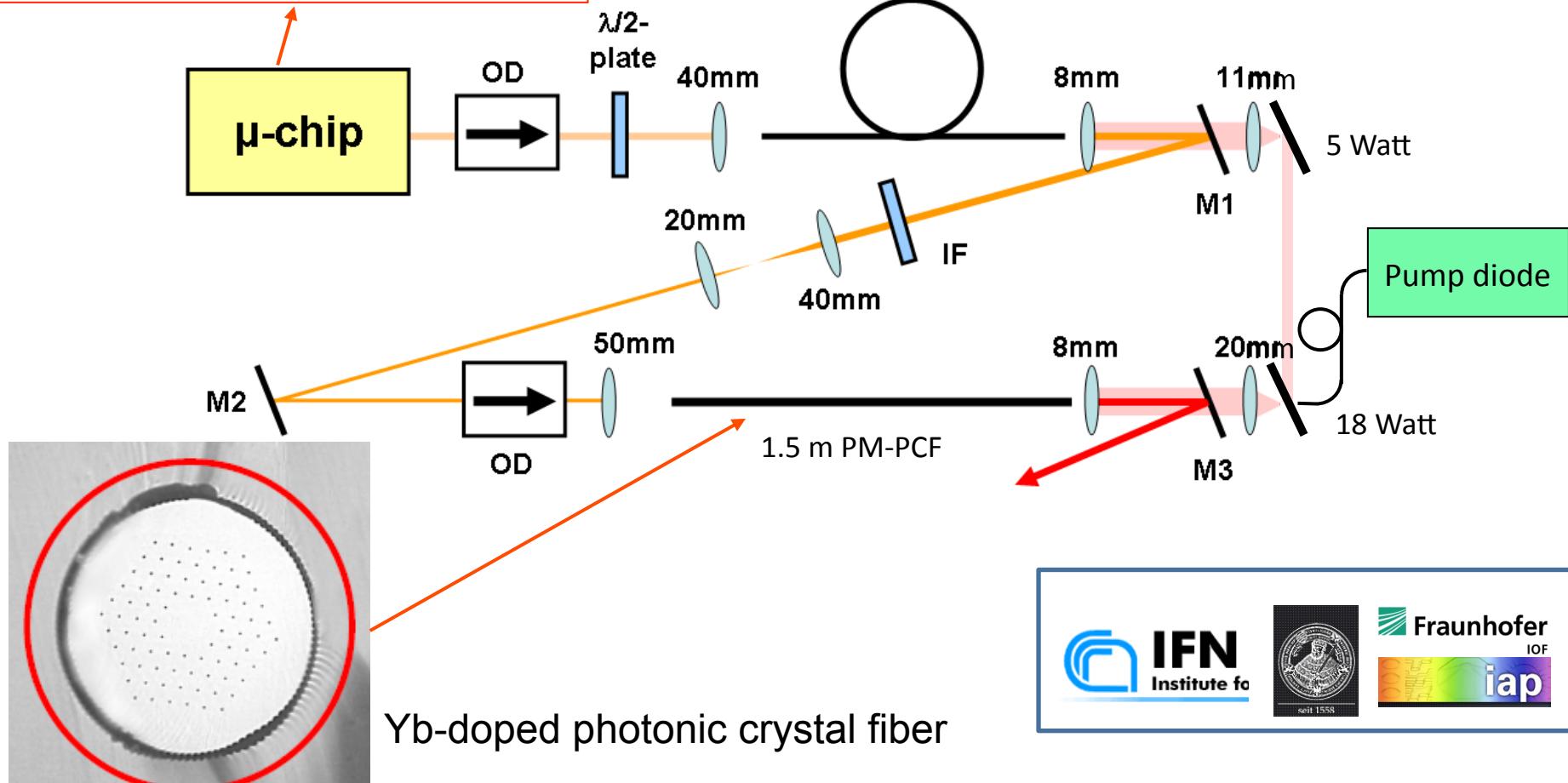
Advantages

Flexible technology: complete control of the hole morphology (taper, diameter) and geometry (density of the holes mm⁻², distribution)

Microchip laser fiber amplifier (100 ps)

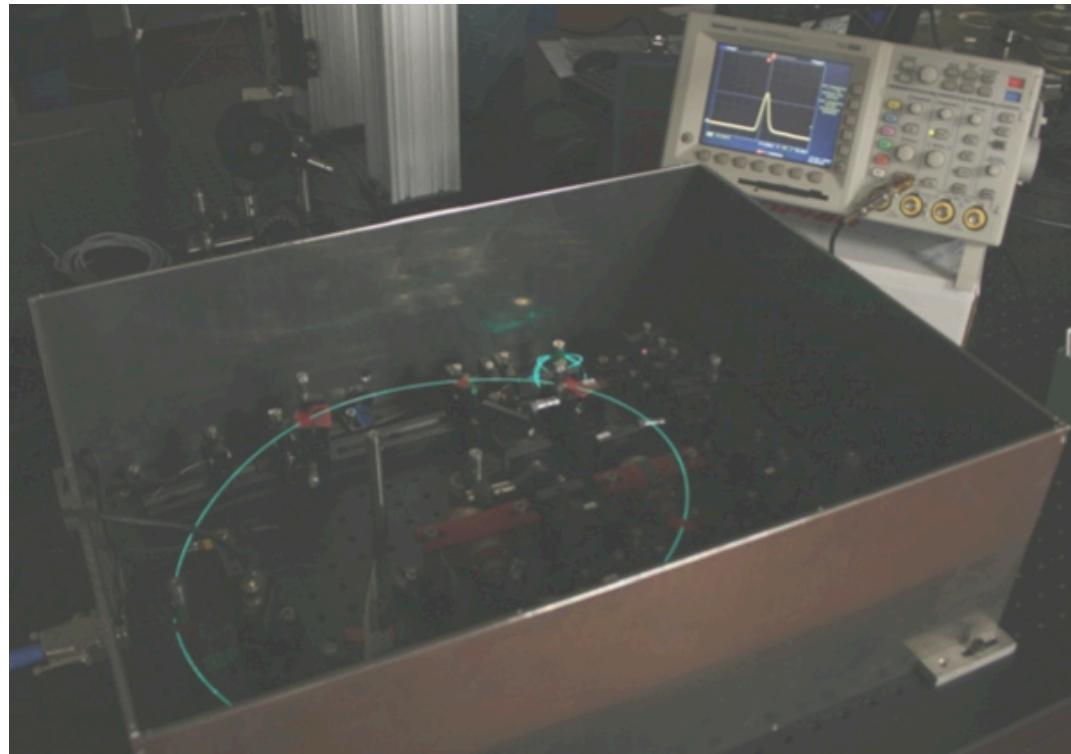


Quasi-monolithic Q-switched microchip laser



CNR-IFN Bari - Laser materials processing lab

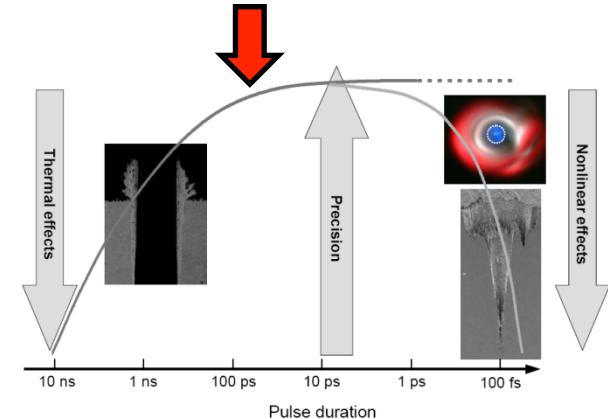
Short pulse 100 ps fiber laser



Collaboration



FSU JENA

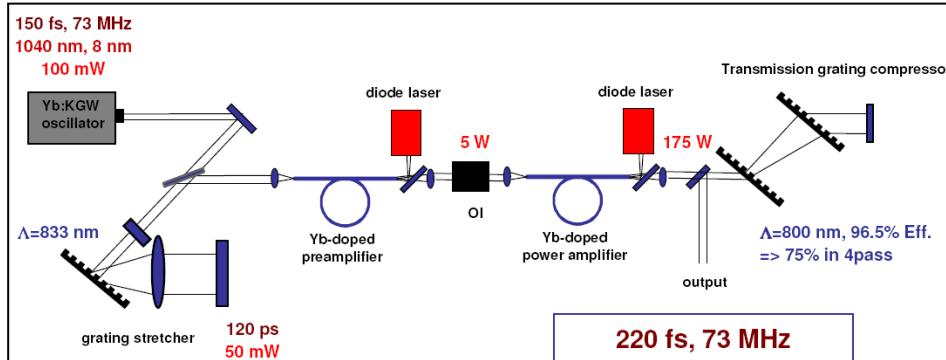


Specifications

Wavelength	1064 nm
Pulse duration	100 ps
Repetition rate	≈ 100 kHz
Pulse energy max.	100 μ J
Average power	10 W
Peak power max.	1 MW

CNR-IFN Bari - Laser materials processing lab

Ultrafast high power fiber CPA lasersystem



Wavelength: 1030 nm

Repetition rate: < 50 kHz ... >10 MHz

Average power: up to 50 W

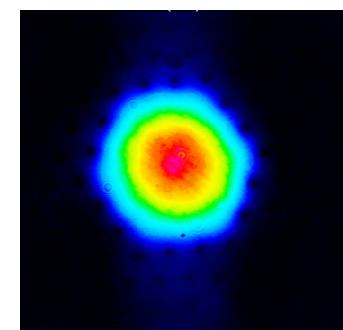
Pulse energy: up to 100 μ J

Pulse duration: < 500 fs ... >20 ps

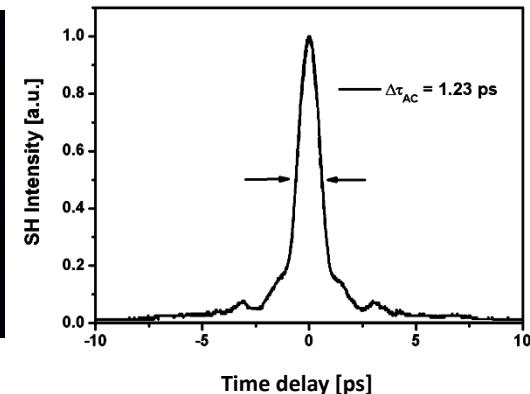
Beam quality: $M^2 < 1.5$

Options: SHG (515 nm), THG (345 nm)

mode profile



autocorrelation



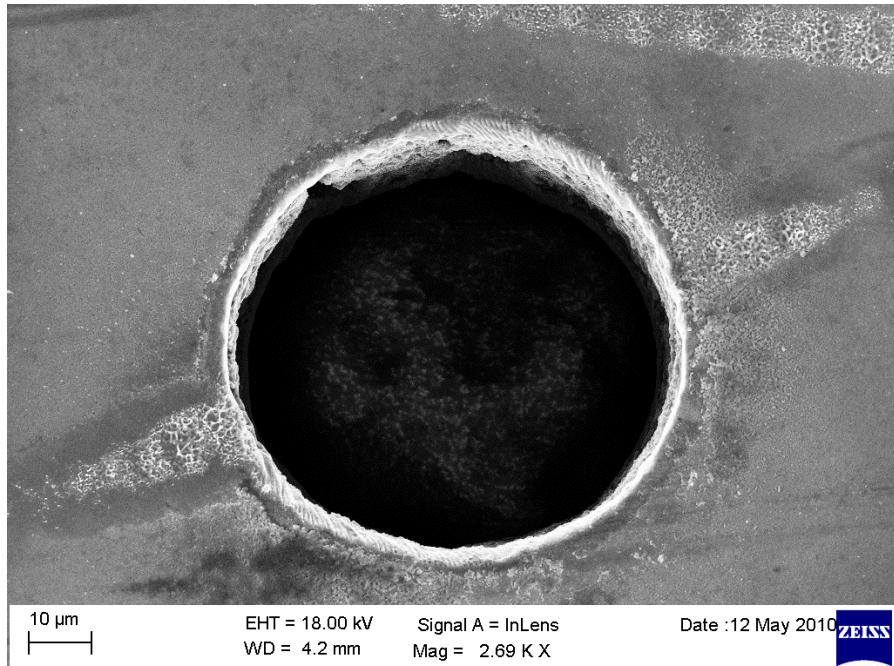
Post process Analysis

- Electron Microscopy - Field Emission
- EDS (Energy Dispersive X-ray Spectroscopy)
- Optical microscopy
- Profilometry

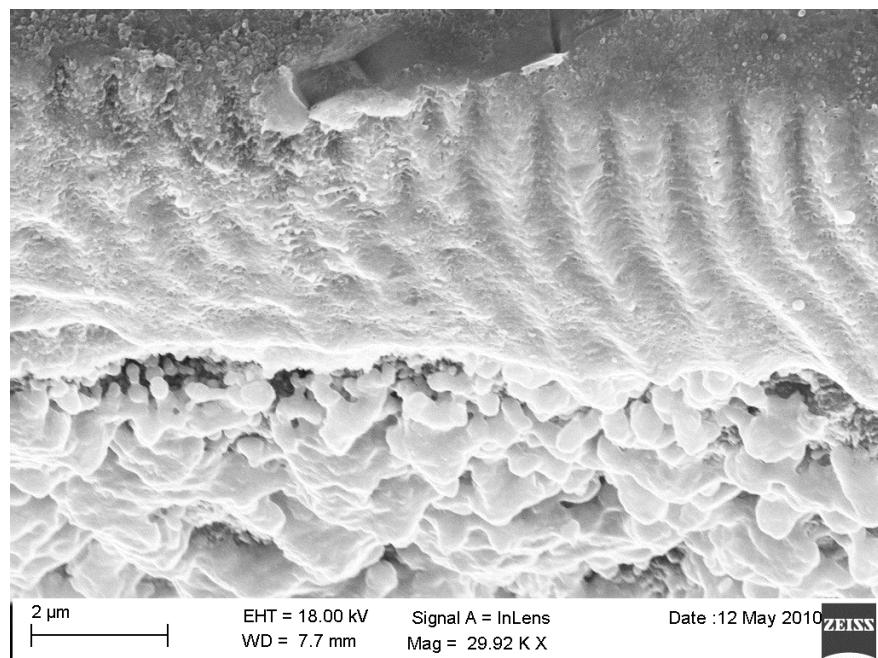


Preliminary results

Laser trepanned hole



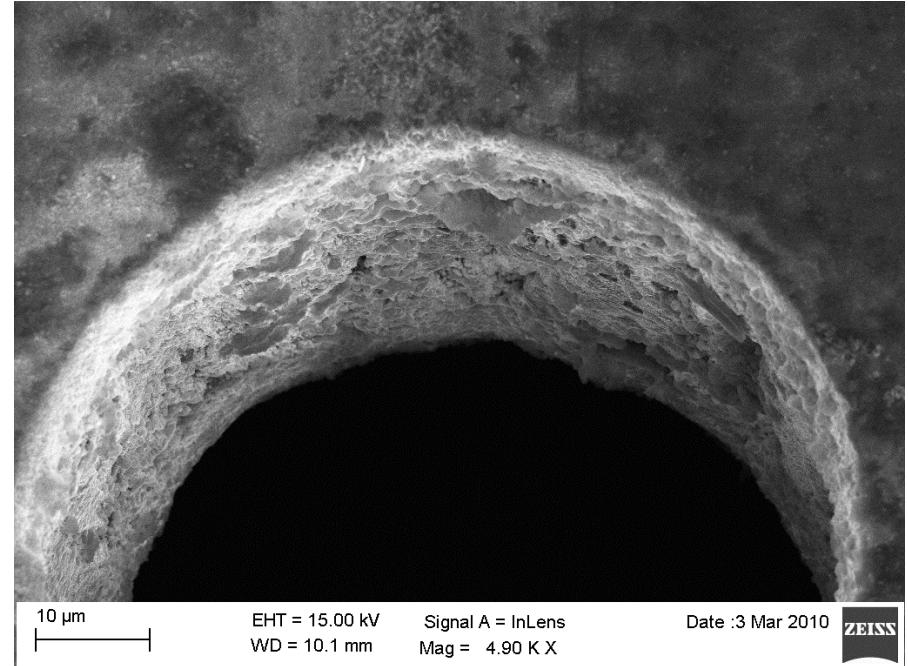
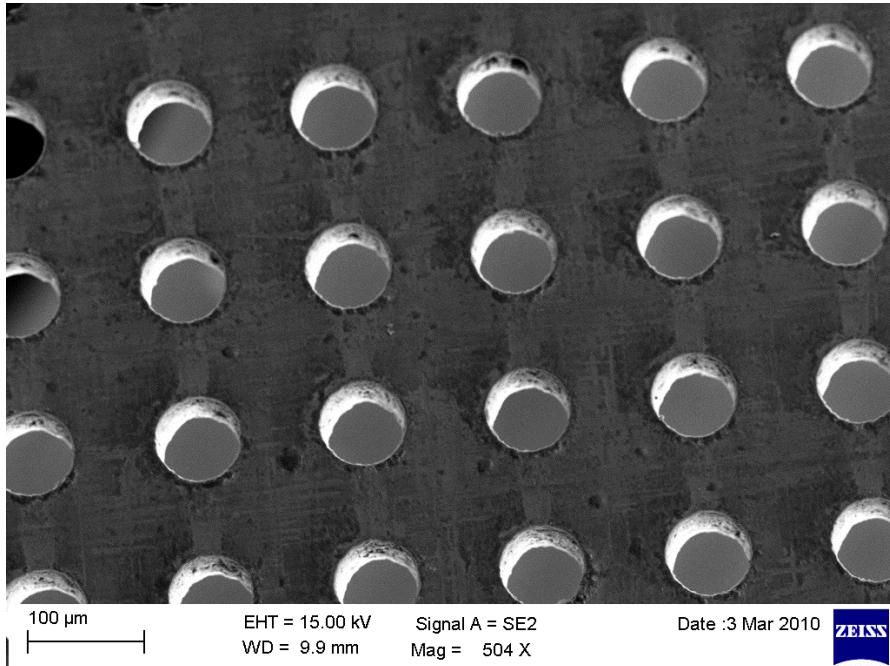
Cu – Kapton internal edge



Laser parameters:

- wavelength: 1064 nm
- pulse duration: 100 ps
- repetition rate: 100 kHz
- average power: 0.7 W
- spot size: 30 µm
- trepanning radius: 20 µm

Preliminary results



- 😊 High repeatability
- 😢 Cu particle redeposition inside the hole
 - ⇒ electric isolation not always guaranteed
 - ⇒ post-process etching needed

Outlook

- ❑ Etching tests to remove the Cu redeposited particles inside the hole in order to prevent voltage failures
- ❑ Laser trepanning assisted by an inert gas flow (or trepanning with smaller spot size) to avoid particle redeposition
- ❑ Micromegas (Cu 5 μ m/18 μ m) small pitch laser machining (focusing spot down to < 10 μ m)
- ❑ Ceramic (Al_2O_3) laser drilling for thick GEM fabrication

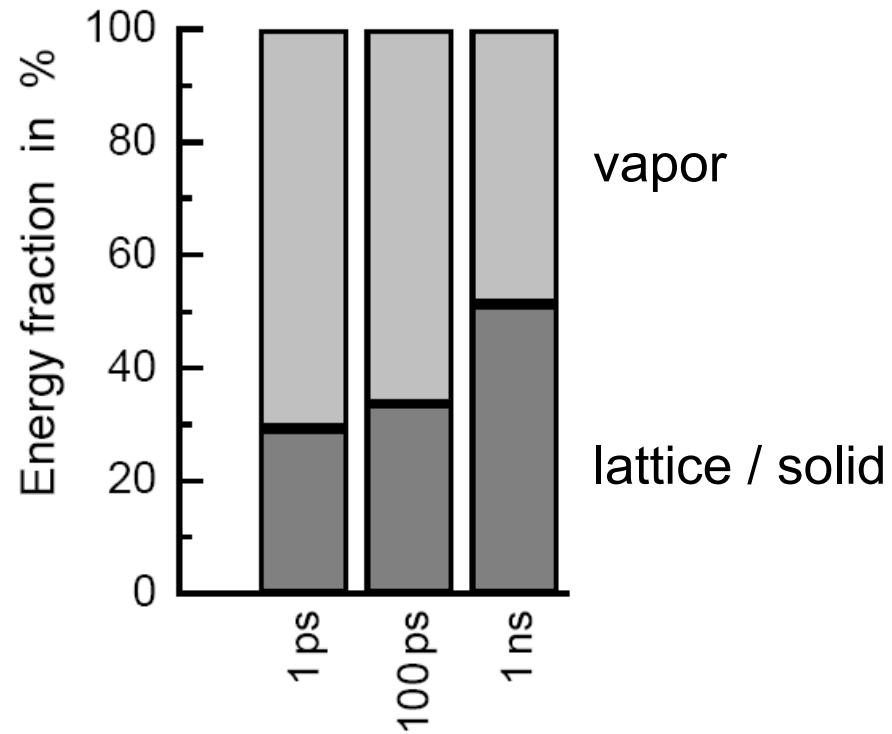
Laser Material Processing Research Group

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INFN Bari Collaboration

Gabriella Catanesi	INFN, Senior reseracher
Vincenzo Berardi	Politecnico di Bari, associate professor

Pulse energy distribution during laser ablation



absorbed laser energy :

- plasma generation and bond breaking
- particle ablation
- **residual thermal energy**

D. Breitling et al. „Fundamental aspects in machining of metals with short and ultrashort laser pulses“, Proc. of SPIE **5339** (2004), 49-63